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(FILE 'HOME' ENTERED AT 12:11:55 ON 30 JUL 2001)

FILE 'CAPLUS, SCISEARCH, USPATFULL' ENTERED AT 12:12:11 ON 30 JUL 2001

L1	50084 S SUPERLATTICE
L2	2348 S L1 (P) (THIN (2A) FILM)
L3	40 S L2 (P) ARRAY
L4	37 DUP REM L3 (3 DUPLICATES REMOVED)
L5	35 S L2 (P) (SCREEN? OR TEST?)
L6	27 DUP REM L5 (8 DUPLICATES REMOVED)

=>

L6 ANSWER 1 OF 27 USPATFULL

ACCESSION NUMBER: 2001:47390 USPATFULL

TITLE: Thin film structure machining and attachment

INVENTOR(S): Cheung, Patrick C. P., Castro Valley, CA, United States

Berlin, Andrew A., San Jose, CA, United States

Biegelsen, David K., Portola Valley, CA, United States

Lau, Rachel King-Ha, Fremont, CA, United States

Yim, Mark H., Palo Alto, CA, United States

PATENT ASSIGNEE(S): Xerox Corporation, Stamford, CT, United States (U.S. corporation)

	NUMBER	KIND	DATE
PATENT INFORMATION:	US 6210514	B1	20010403
APPLICATION INFO.:	US 1998-22173		19980211 (9)
DOCUMENT TYPE:	Utility		
FILE SEGMENT:	Granted		
PRIMARY EXAMINER:	Mayes, Curtis		
LEGAL REPRESENTATIVE:	Oliff & Berridge, PLC		
NUMBER OF CLAIMS:	12		
EXEMPLARY CLAIM:	1		
NUMBER OF DRAWINGS:	27 Drawing Figure(s); 14 Drawing Page(s)		
LINE COUNT:	733		

DETD . . . polymeric membrane 24, by deposition of large numbers of particles or liquid through

traditional thick film technologies such as silk **screening**, spin coatings, or painting, by

contact transfer of film from a separate liquid or solid support to the **thin film**

support 25, or by any other conventional deposition or transfer technique. As will be appreciated,

films do not have to be homogeneous materials, but can be heterogeneously patterned, have structured

compositions or be formed to have **superlattices**. Multilayer or structured layers are also

contemplated to be within the scope of the present invention. Generally, films are on. . .

L4 ANSWER 33 OF 37 USPATFULL

ACCESSION NUMBER: 87:61834 USPATFULL

TITLE: Micro-porous superlattice separations

INVENTOR(S): Roxlo, Charles B., Bridgewater, NJ, United States

Deckman, Harry W., Clinton, NJ, United States

PATENT ASSIGNEE(S): Exxon Research and Engineering Company, Florham Park,
NJ, United States (U.S.

corporation)

	NUMBER	KIND	DATE
PATENT INFORMATION:	US 4690750		19870901
APPLICATION INFO.:	US 1986-874027		19860613 (6)
DOCUMENT TYPE:	Utility		
FILE SEGMENT:	Granted		
PRIMARY EXAMINER:	Metz, Andrew H.		
ASSISTANT EXAMINER:	Caldarola, Glenn		
LEGAL REPRESENTATIVE:	Hantman, Ronald D.		
NUMBER OF CLAIMS:	10		
EXEMPLARY CLAIM:	1		
NUMBER OF DRAWINGS:	14 Drawing Figure(s); 8 Drawing Page(s)		
LINE COUNT:	708		

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

DETD **Superlattices** consisting of **thin film** layers 5-2500 .ANG. thick,
provide

a unique template for forming two dimensional pores with precisely
controlled surface chemistry. By

breaking the **thin film** up in a manner that exposes edges of the **thin
film** layers it is possible to create a slotted structure by
selectively etching away one or

more of the materials comprising the **superlattices**. FIG. 1 shows a
schematic diagram of a

fabrication sequence used to create controlled dimension pores in
superlattice zeolite-like

materials. In the sequence shown in FIG. 1 alternating **thin film**
layers 1,3 are

sequentially deposited onto a substrate 5. The lithographic template
formed by the alternating layers

1,3 is exposed. . . exposed at the post edge is selectively etched,
slots 13 are formed in the post

and the material containing the **array** of etched slots is referred to
as a micro-porous

superlattice material 15. The width and uniformity of the resulting
slot is determined by the

thickness and uniformity of the deposited film. Since **superlattices**
can be grown with layers

that are flat and smooth to better than 5 .ANG., (P. N. Petroff, A.
C.. . . larger molecular

species. Chemistry of the slots can be directly controlled by the
choice of materials used to form the

superlattice.

L4 ANSWER 32 OF 37 USPATFULL

ACCESSION NUMBER: 87:73226 USPATFULL

TITLE: Micro-porous superlattice material having
zeolite-like properties

INVENTOR(S): Deckman, Harry W., Clinton, NJ, United States
Stephens, Richard B., Annandale, NJ, United States
Tiedje, J. Thomas, Lebanon, NJ, United States
Abeles, Benjamin, Annandale, NJ, United States
PATENT ASSIGNEE(S): Exxon Research and Engineering Company, Florham Park,
NJ, United States (U.S.
corporation)

	NUMBER	KIND	DATE
PATENT INFORMATION:	US 4701366		19871020
APPLICATION INFO.:	US 1985-750140		19850701 (6)
DOCUMENT TYPE:	Utility		
FILE SEGMENT:	Granted		
PRIMARY EXAMINER:	Lesmes, George F.		
ASSISTANT EXAMINER:	Rucker, Susan S.		
LEGAL REPRESENTATIVE:	Hantman, Ronald D.		
NUMBER OF CLAIMS:	20		
EXEMPLARY CLAIM:	1		
NUMBER OF DRAWINGS:	10 Drawing Figure(s); 4 Drawing Page(s)		
LINE COUNT:	605		

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

DRWD **Superlattices** consisting of **thin film** layers 5-2500 .ANG. thick,
provide

a unique template for forming two dimensional pores with precisely
controlled surface chemistry. By
breaking the **thin film** up in a manner that exposes edges of the **thin
film** layers it is possible to create a slotted structure by
selectively etching away one or
more of the materials comprising the **superlattices**. FIGS. 1a-1c show a
schematic diagram of
a fabrication sequence used to create controlled dimension pores in
superlattice
zeolite-like materials. In the sequence shown in FIGS. 1d-1c
alternating **thin film**
layers 1,3 are sequentially deposited onto a substrate 5. The
lithographic template formed by the
alternating layers 1,3 is exposed. . . post edge is selectively
etched, slots 14 are formed in the
post between layers 11 and the material containing the **array** of etched
slots is referred to
as a micro-porous **superlattice** material 15. The width and uniformity
of the resulting slot
is determined by the thickness and uniformity of the deposited film.
Since **superlattices** can
be grown with layers that are flat and smooth to better than 5 .ANG.,
(P. N. Petroff, A. C. . . .
larger molecular species. Chemistry of the slots can be directly
controlled by the choice of materials
used to form the **superlattice**.

ACCESSION NUMBER: 1998:108645 USPATFULL
TITLE: Bismuth layered structure pyroelectric detectors
INVENTOR(S): Ramer, O. Glenn, Los Angeles, CA, United States
Robinson, David A., Oceanside, CA, United States
Drab, John J., Encinitas, CA, United States
PATENT ASSIGNEE(S): Raytheon Company, Lexington, MA, United States (U.S.
corporation)

	NUMBER	KIND	DATE
PATENT INFORMATION:	US 5804823		19980908
APPLICATION INFO.:	US 1995-540533		19951010 (8)
DOCUMENT TYPE:	Utility		
FILE SEGMENT:	Granted		
PRIMARY EXAMINER:	Glick, Edward J.		
LEGAL REPRESENTATIVE:	Schubert, W. C., Lenzen, Jr., G. H.		
NUMBER OF CLAIMS:	13		
EXEMPLARY CLAIM:	1		
NUMBER OF DRAWINGS:	7 Drawing Figure(s); 5 Drawing Page(s)		
LINE COUNT:	440		

SUMM . . . and other problems are overcome and the objects of the invention are realized by a pyroelectric detector comprised of a **thin film** of bismuth layered material. The inventors have discovered that this class of ferroelectric material, which was previously unknown for use. . . changes in the dielectric constant or dielectric loss of a material with temperature, enables the fabrication of thermal detectors and **arrays** of thermal detectors that overcome the problems inherent in many conventional pyroelectric materials. The bismuth layered materials have a naturally occurring "**superlattice**" which enables the properties of the material to be varied by a change in the bismuth concentration in the starting. . . be tailored over a broad range because the ceramic compositions have high solid solubility within each other. These bismuth layered **superlattice** materials are shown to be suitable for the fabrication of "room temperature" infrared detectors or detector **arrays**.

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42
68
70
72
~~74~~
84
88

51-56 density

60 ceramic

64 deliv as sold

65 sequentially

66 2 pin

67 layers different

68 wiring New net

69 1D

70 5 layers

71 Screening (1D)

72 1D or more regions

74 1D

75 2 pinners

77 barrier types

78 more

92-95

80 consist
ess. of

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8 1/2nd
Y differ

10 diff units 1st

11 diff units 2nd

15-22 #s compels

24 deliv tech.

26 useful prop

30-35 # components
at 1st unit.

42

43 screening

45 layers

46 2 pinners
47 more